Structure and Thermochemistry of p-Silicon Carbenium Ions in the Gas Phase

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Both protonation of trimethylvinylsilane and addition of Me₃Si+ to ethylene in the gas phase produce the cation $Me₃Si(CH₂CH₂)$ ⁺, with 39 kcal mol⁻¹ stabilization energy relative to ethyl cation; however, chloride abstraction from Me₃SiCHCICH₃ yields a mixture of ions resulting from competing methyl and hydrogen shifts in the nascent silylcarbenium ion.

One of the most spectacular substituent effects in organic chemistry is the powerful stabilizing influence of a β -silyl group? on carbenium ion intermediates in solvolytic reactions. Numerous condensed-phase experimental investigations and computational studies of the so-called ' β -silicon effect' have been carried out since the phenomenon was first noted by Ushakov and Itenberg in **1937.1-14** We report here an

t **The carbenium carbon atom is considered** to **be the or-position.**

experimental determination of the extent of stabilization and structural consequences of both α - and β -silyl substitution in simple gas-phase carbenium ions formed in a flowing afterglow-triple quadrupole apparatus at $298 K.$ #

Our investigation concerns the family of ions C₅H₁₃Si⁺ (m/z)

^{\$} **A complete description of the apparatus will be given in a future publication. For a preliminary account see ref. 15. All experiments were carried out using** $p(He) = 0.4$ **Torr;** $v(He) = 9400$ **cm s⁻¹.**

101) that can be generated in the helium flow reactor by several different methods. Reaction between trimethylsilicenium ion (formed by electron ionization of Me₄Si or Me₆Si₂) and ethylene at 0.4 Torr total pressure yields exclusively the termolecular addition product (1) [equation (1)]. This ion undergoes collision-induced dissociation $(c.i.d.)$ in the triple quadrupole analyser by loss of ethylene with a measured energy threshold (E_T) of 0.8 ± 0.1 eV. § Collisional activation of the C_2D_4/Me_3Si^+ adduct results in loss of only C_2D_4 , showing that hydrogen scrambling does not take place within the ion. The bimolecular reactions of the ion **(1)** with methanol, benzene, and other *n-* or n-donor Lewis bases are relatively rapid $(k = 2 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1})$ and result mainly or exclusively in ethylene displacement¹⁷ [equation (2)]. g that hydrogen scrambling does not take place within

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Me3Si+ + CH2=CH2 \xrightarrow{\text{[He]}} Me3Si(CH2CH2)+ (1)
$$

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 and result mainly or
exclusively in ethylene displacement¹⁷ [equation (2)].

 $Me_3\text{Si}^+ + \text{CH}_2=\text{CH}_2 \xrightarrow{[He]} Me_3\text{Si}(\text{CH}_2\text{CH}_2)^+$ (1)

 $Me_3\text{Si}(\text{CH}_2\text{CH}_2)^+ + B \xrightarrow{100\%} Me_3\text{Si}(B)^+ + \text{CH}_2=\text{CH}_2$ (2)
 $B = \text{MeOH}, C_6H_6$

This behaviour **is** indicative of an ion structure with an intact but labile ethylene ligand. Both open **(la)** and silicon-bridged **(lb)** structures are consistent with the observed reactivity. High-energy (3 kV) collisional activation experiments by Ciommer and Schwarz with ¹³C- and CD₂-labelled C₅H₁₃Si⁺ ions formed by dissociative ionization of $Me₃SiCH₂CH₂OPh$ derivatives show that the methylene groups in the ethylene ligand become equivalent prior to, or during c.i.d.12 Moreover, *ab initio* calculations for both $H_3Si(CH_2CH_2)^+$ and $Me₃Si(CH₂CH₂)⁺$ predict that the Si-bridged forms are lower in energy than the open forms.11-13

Protonation of trimethylvinylsilane Me₃SiCH=CH₂ (2) by any of a variety of cationic Brensted acids [equation (3)] MeOH to yield an addition product *and* an ethylene displacement product in an approximately 4: 1 yield ratio. Since neither C_3H_6 loss nor adduct formation with MeOH are observed with protonated Me₃SiCH=CH₂, then formation of the α -silyl carbenium ion by protonation β to silicon does not occur. This apparent selectivity **is** surprising in view of the fact that the developing carbenium ion formed by α -protonation cannot fully benefit from the favourable bridging/hyperconjugative interactions of the β -silyl group since the vacant carbon 2p orbital and the C-Si bond are initially perpendicular.13 A likely explanation is that the conjugate base of the protonating agent [B in equation (3)] mediates the proton transfer reaction in the ion/molecule collision complex by interacting with the nascent carbenium ion in a Lewis-base fashion. **¹⁸**

It can be shown that chloride loss from $Me₃SiCHClCH₃$, in fact, yields a *mixture* of isomeric ions arising from competing 1,2-H and 1,2-methyl shifts within the nascent α -trimethylsilylcarbenium ion [equation (4)]. An authentic ion $Me₂Si⁺$. CH(CH3)2. **(3)** formed by chloride abstraction from the corresponding chlorosilane reacts with MeOH exclusively by addition, whereas the authentic hydrogen shift product **(1)** reacts exclusively by C_2H_4 displacement. In a recent experimental and theoretical investigation of these same $C_5H_{13}Si^+$ ions,¹³ Apeloig, Schwarz, and their co-workers concluded that the trimethylsilyl carbenium ion rearranges entirely by the 1,2-methyl shift pathway to yield only **(3),** since the high energy collisional activation spectra of authentic **(3)** and the product of Cl-loss from Me₃SiCHClCH₃ were found to be identical. We also find the c.i.d. spectra of **(3)** and the ion mixture from $Me₃SiCHCICH₃$ to be similar over a range of conditions of collision energy and target gas pressure in the triple quadrupole. Nevertheless, the results of the bimolecular reactions with MeOH clearly show that Me₃SiCHClCH₃ produces a *mixture* of $C_5H_{13}Si$ ⁺ ions consisting of roughly 80% **(3)** and 20% **(1).**

P+ ⁺1,2-CH-3 Me3SiCHC1CH3 [Me3SiCHCH3] - Me2&iCH(CH3) **(3)** 1,2-H ---+ Me3Si(CH2CH2)+ **(4) (1)**

produces an ion $C_5H_{13}Si^+$ that exhibits behaviour identical with that of the ion (1) . Thus, protonated Me₃SiCH=CH₂ undergoes c.i.d. by C_2H_4 loss with a 0.6 \pm 0.2 eV energy threshold, § and reacts with MeOH, C_6H_6 , and other Lewis

bases by exclusive ethylene displacement.
\n
$$
Me_3SiCH=CH_2 + BH^+ \longrightarrow Me_3Si(CH_2CH_2)^+ + B
$$
\n(3)
\n
$$
BH^+ = C_2H_5^+, H_3O^+, Me_3C^+
$$

Exclusive α -protonation of Me₃SiCH=CH₂ yielding the ion **(1)** is required by the foregoing results since an 'authentic' a-trimethylsilyl carbenium that would be derived from protonation β to silicon exhibits *different* unimolecular and bimolecular reactivity. For instance, the ion $C_5H_{13}Si^+$ resulting from chloride abstraction from (or protonolysis of) $Me₃Si-$ CHClCH₃ by Me₃C⁺ fragments in the triple quadrupole by loss of *both* C_2H_4 and C_3H_6 with similar yields, and reacts with

The total stabilization energy in the
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-silyl carbonium ion (1) can be experimentally evaluated from the measured proton affinity (P.A.) of Me₃SiCH=CH₂. Proton transfer equilibrium involving Me₃SiCH=CH₂ and Me₃Si(CH₂CH₂)⁺ cannot be established because of the strong tendency for Me₃Si(CH₂CH₂)⁺ to react by C₂H₄ displacement rather than proton transfer with most reference bases. However, by combining a conventional proton affinity bracketing approach¹⁹ with careful monitoring of the kinetic energy dependence of proton transfer reactions taking place in the triple quadrupole collision chamber,²⁰ we have arrived at a consistent value for P.A.(Me₃SiCH=CH₂) of 199 ± 2 kcal mol⁻¹.

A proton affinity of 199 kcal mol⁻¹ ranks $Me₃SiCH=CH₂$ among isobutene (P.A. 196), tetramethylethylene **(P.A.** 199) and styrene $(P.A. 202$ kcal mol⁻¹) with respect to base

(1 b)

⁸ Energy thresholds for fragmentation reactions are determined under single collision conditions in the middle quadrupole from a linear fit of the steeply rising portion of a plot of normalized product ion intensity *versus* centre-of-mass collision energy. The energy axis origin **is** located with retarding potential analysis and the apparent thresholds are corrected for Doppler broadening.¹⁶ (1a)

strength.19 Therefore the total stabilization energy of the ion (1) relative to protonated ethylene $(P.A. 162.6$ kcal mol⁻¹)¹⁹ **is similar to that of tertiary and benzylic carbenium ions. The stabilization energy relative to hydrogen in an ethyl cation is formally given by the hypothetical hydride transfer reaction in equation** (5).¹⁰ Using $\Delta H_f(1) = 138 \pm 4$ kcal mol⁻¹ derived **from the measured proton affinity and an estimate for** ΔH_f (Me₃SiEt), we compute $\Delta H(5) = 39$ kcal mol⁻¹. This is **in good agreement with the theoretical stabilization energy for** H₃Si(CH₂CH₂)⁺ of 38 kcal mol⁻¹ reported by Jørgensen and **co-workers. 11**

$$
Me3Si(CH2CH2)+ + CH3CH3 \rightarrow Me3SiCH2CH3 + C2H5+ (5)
$$

This research was supported by a grant from the National Science Foundation (CHE-8502515). R. R. S. thanks the Alfred P. Sloan Foundation for a fellowship.

Received, 22nd December 1987; Corn. 1839

References

- **1 S.** N. Ushakov and A. M. Itenberg, *Zh. Obshch. Khim.,* **1937,7, 2495.**
- **2** (a) L. **H.** Sommer and F. C. Whitmore, J. *Am. Chem. SOC.,* **1946, 68,485;** (b) **L.** H. Sommer and G. A. Baughman, *ibid.,* **1961,83, 3346.**
- **3 (a)** C. Eaborn and R. W. Bott, in 'Organometallic Compounds of the Group IV Elements,' ed. A. G. MacDiarmid, Dekker, New York, **1968,** vol. **1,** part **1;** (b) R. W. Bott, C. Eaborn, and B. M. Rushton, J. *Orgunomet. Chem.,* **1965,3,455;** (c) M. **A.** Cook, C. Eaborn, and R. M. Walton, *ibid.,* **1970, 24, 301.**

 $\int \Delta H_f(Me_3S)CH=CH_2$, g) = -29 \pm 3 kcal mol⁻¹; $\Delta H_f(Me_3S)$ CH_2CH_3 , g) = -59 \pm 2 kcal mol⁻¹ estimates based on ΔH_f (Me₄Si, g) $= -54.1 \pm 1.1$ kcal⁻¹ mol)²¹ and assumed energy increments for replacing methyl with ethyl and vinyl; *cf.* ref. **22.**

- **4** (a) **A.** W. P. Jarvie, *Organomet. Chem. Rev. A,* **1970,6, 153;** (b) **A.** W. P. Jarvie, A. Holt, and J. Thompson, J. *Chem. SOC. B,* **1969, 852;** (c) A. W. P. Jarvie, **A.** Holt, and J. Thompson, *ibid.,* **1970,746.**
- 5 J. Vencl, J. Hetflejs, J. Cermak, and V. Chvalovsky, *Coll. Czech. Chem. Commun.,* **1973,38, 1256.**
- 6 D. D. Davis and H. M. Jacocks, J. *Organomet. Chem.,* **1981,206, 33.**
- **7** (a) **J.** B. Lambert and R. B. Finzel, J. *Am. Chem. SOC.,* **1982,104, 2020;** (b) J. B. Lambert, G. Wang, R. B. Finzel, and D. H. Teramura, *ibid.,* submitted for publication.
- 8 C. G. Pitt, J. *Organomet. Chem.,* **1973, 61, 49.**
- **9** C. Eaborn, F. Feichtmayr, M. Horn, and J. N. Murrell, J. *Orgunomet. Chem.,* **1974, 77,39. 10** Y. Apeloig, P. von R. Schleyer, and J. A. Pople, J. *Am. Chem.*
- **SOC., 1977, 99, 5901.**
- 11 S. G. Wierschke, J. Chandrasekhar, and W. L. Jørgensen, *J. Am*. *Chem. SOC.,* **1985, 107, 1496.**
- **12** B. Ciommer and H. Schwarz, J. *Orgunomet. Chem.,* **1983,** *244,* **319.**
- **13** Y. Apeloig, **M.** Karni, A. Stanger, H. Schwarz, T. Drewello, and G. Czekay, J. *Chem. SOC., Chem. Commun.,* **1987,989.**
- **14** For review **of** the mass spectrometry of silicon-containing molecules, see H. Schwarz in 'The Chemistry of Organosilicon Compounds,' eds. S. Patai and Z. Rappaport, Wiley, New York, in the press.
- **15 R. R.** Squires, K. R. Lane, R. E. Lee, L. G. Wright, K. V. Wood, and R. G. Cooks, *Int.* J. *Muss Spec. Zon Processes,* **1985,64,185.**
- **16** P. J. Chantry, J. *Chem. Phys.,* **1971,55, 2746.**
- **17 A.** C. **M.** Wojtyniak and J. A. Stone, *Znt.* J. *Mass Spec. Zon Processes,* **1986, 74, 59.**
- **18** E. W. Redman and T. H. Morton, J. *Am. Chem.* **SOC., 1986,108, 5701.**
- **19 S.** G. Lias, J. F. Liebman, and R. D. Levin, J. *Phys. Chem. Ref. Data,* **1984, 13, 695.**
- **20** M. T. Kinter and M. M. Bursey, *Org. Muss Spectrom.,* **1987, 22, 775.**
- **21** L. Szepes and T. Baer, J. *Am. Chem.* **SOC., 1984, 106, 273.**
- **22 S.** W. Benson, 'Thermochemical Kinetics,' 2nd edn., Wiley Interscience, New York, **1976.**